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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/530,677	11/10/2005	1756	1030	SOEI0018	1	17	1

24203
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RECEIVED
 FEB 17 2006

CONFIRMATION NO. 7706

FILING RECEIPT



OC000000018044600

Date Mailed: 02/16/2006

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Assignment For Published Patent Application

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Power of Attorney: The patent practitioners associated with Customer Number **24203**.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/12910 10/08/2003

Foreign Applications

JAPAN 2002-295287 10/08/2002

Projected Publication Date: 05/25/2006

Non-Publication Request: No

Early Publication Request: No

Title A PHOTSENSITIVE RESIN COMPOSITION, PHOTSENSITIVE ELEMENT
USING SAME, RESIST PATTERN FORMING METHOD AND PRINTED
CIRCUIT BOARD

Photosensitive resin composition, and photosensitive element, method for forming resist pattern and printed wiring board using the composition

Preliminary Class

430

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